A Self-Consistent Discretization Scheme for Current and Energy Transport Equations

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Abstract

We propose a discretization scheme which implements the box integration / Scharfetter-Gummel method for a new Energy Transport model. The discretization treats consistently the current and energy flux and avoids typical problems encountered in many hydrodynamic formulations. Simulation results are satisfactory from both the numerical and physical points of view.

1 Introduction

In recent years, much effort [1]-[5] has focused on extending the Scharfetter-Gummel (S-G) scheme [6], which results in excellent numerical stability and retains reasonable accuracy in Drift-Diffusion simulation, to the case including the energy transport equation (e.g. hydrodynamic (HD) models). However, these discretization methods are not truly self-consistent in terms of current and energy flux, since the assumptions used in discretizing the local energy transport equations, are different from those in the local current equations. In addition, the resulting formulations of the energy balance equation pose considerable difficulties in the numerical implementation.

We discuss here the discretization of a novel Energy Transport (ET) model [7] briefly described in Sec. II, which avoids the direct use of the phenomenological Wiedmann-Franz law in conventional HD models and employs an elegant parallel between the expressions for the current and the energy flux. The self-consistent discretization scheme based on the ET model is a natural extension of the S-G scheme and has been implemented in a 2-D simulator. To demonstrate the features of this model, we compare our numerical results with HD simulations, for the well known case of Si $n^+ - n - n^+$ test structures.

2 Physical Model

The 0th and 2nd order moments of the BTE give the carrier continuity and energy balance equations:

$$\nabla \cdot J = G - R;$$

(1)

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\[ \nabla \cdot \mathbf{S} = \mathbf{F} \cdot \mathbf{J} - n < \frac{\partial E}{\partial t}_{\text{coll}} > \] (2)

where \( \mathbf{F} \) is the electric field, \( \mathbf{J} = -qn < \mathbf{v} > = -q \int d^3 k \mathbf{v} f \) and \( \mathbf{S} = n < E \mathbf{v} > = \int d^3 k E \mathbf{v} f \). Here, \( q \) is the elementary charge, \( n \) is the carrier concentration, \( \mathbf{v} \) is the carrier velocity, \( \mathbf{k} \) is the crystal momentum, \( f \) is the distribution function and \( E \) is the carrier energy. To derive \( \mathbf{J} \) and \( \mathbf{S} \) from the BTE as functionals of \( n \) and \( < E > \), the distribution function \( f \) is decomposed as \( f = f_0 + f_1 \) with \( f_0 \) and \( f_1 \) as even and odd functions, respectively. We further use the microscopic relaxation time approximation for the collision term, \( (\partial f/\partial t)_{\text{coll}} = -f_1/\tau \), assuming \( f_1 \ll f_0 \) (as given for instance by Stratton [8]) and then obtain

\[ f_1 = \frac{q \tau F}{h} \nabla_k f_0 - \tau \mathbf{v} \nabla f_0 . \] (3)

Substitution of (3) into the expressions for \( \mathbf{J} \) and \( \mathbf{S} \) will yield

\[ \mathbf{J} = -q \int d^3 k \mathbf{v} f_1 = q(n \mu \mathbf{F} + \nabla \cdot (n \mathbf{D})); \] (4)

\[ \mathbf{S} = \int d^3 k E \mathbf{v} f_1 = -n \mu^E \mathbf{F} - \nabla \cdot (n \mathbf{D}^E), \] (5)

which resemble the perturbed BTE solution approach in [9]. The transport coefficients \( \mu, \mathbf{D}, \mu^E, \) and \( \mathbf{D}^E \), all of which we can model as functions of \( < E > \), are tensors and can be determined from the knowledge of \( f_0 \). The divergence of tensor in (4) and (5) means to take the divergence of each row of the tensor as a vector element. The following approximations for \( f_0(\mathbf{k}) \) and the energy \( E(\mathbf{k}) \) are used to obtain a complete set of transport coefficients:

1) nonparabolic bands: \( \hbar^2 k^2/2m^* = E(1 + \alpha E); \)
2) non-Maxwellian effects: \( f_0 = (1 + \gamma E/k_B T_e) f_m(E) \), where \( f_m(E) \) is the Maxwellian distribution at an elevated temperature \( T_e \) and \( \gamma \) is the non-Maxwellian parameter;
3) field-induced anisotropy [10]: \( f_0(\mathbf{k}) = \frac{1}{2} [f_m(E(\mathbf{k} + \mathbf{k}_0)) + f_m(E(\mathbf{k} - \mathbf{k}_0))].\)

It is very important to notice that in this approach all of the necessary transport parameters can be determined, for instance, from bulk Monte Carlo simulations and that the Wiedmann-Franz law for heat flow is never invoked, as it is necessary in the conventional hydrodynamic method.

### 3 Discretization Scheme

For Si, the correction from the field-induced anisotropy is generally not important [10]. With assumptions 1) and 2) above, \( \mu, \mathbf{D}, \mu^E, \) and \( \mathbf{D}^E \) will degenerate to scalar forms and the modified Einstein relations are valid between \( \mu \) and \( \mathbf{D} \) and between \( \mu^E \) and \( \mathbf{D}^E \)

\[ D = \frac{k_B T_m}{q} \mu ; \] (6)

\[ D^E = \frac{k_B T_m}{q} \mu^E \] (7)

where \( T_m = (1 + \gamma)T_e \) is an approximation for the carrier temperature with the relation to the mean carrier energy as

\[ < E > \approx (1 + \frac{5}{2}a k_B T_m)\frac{3}{2}k_B T_m . \] (8)
Furthermore, \( \mu \) and \( \mu^E \) are related by
\[
\mu^E = \left( \frac{5}{2} - p \right)(1 - \frac{\alpha k_B T_m}{2}) k_B T_m \mu = C \mu
\]
where \( p \) depends on the dominant scattering mechanism and is derived from the power law of the microscopic relaxation time, \( \tau(k) \propto E^{-p} \). The parameter \( p \) is constant for a Maxwellian-like distribution and is a slowly varying function of the mean carrier energy for a non-Maxwellian distribution, which ranges from 0.5 to 1.0 according to our bulk Monte Carlo simulations. Substituting (6), (7) and (9) into (4) and (5), we can write the normalized expressions for \( J \) and \( S \) as
\[
\begin{align*}
\dot{J} &= -N \nabla \psi + \nabla (NT) ; \\
\dot{S} &= -NT \nabla \psi + \nabla (NT^2)
\end{align*}
\]
where \( N = n \mu \), \( T \) is the carrier temperature normalized to the lattice temperature \( T_0 \), and \( \psi \) is the electrical potential. The similarity of the functional expressions in (10) and (11) serves as the basis for our extended Scharfetter-Gummel discretization for both continuity and energy balance equations. In order to perform the standard box integration around each discretization node, we need to know \( \dot{J} \) and \( \dot{S} \) along each grid line. On the mesh line connecting the nodes \( i \) and \( j \), (10) and (11) can be expressed as:
\[
\begin{align*}
\dot{J}_i &= -N \frac{d \psi}{dl} + \frac{d (NT)}{dl} ; \\
\dot{S}_i &= -NT \frac{d \psi}{dl} + \frac{d (NT^2)}{dl}
\end{align*}
\]
where \( l \) is a coordinate defined on the mesh line. By using the following assumptions
1) \( \dot{J}_i \) and \( \dot{S}_i \) are constants
2) \( (1/T)(d\psi/dl) \) is a constant
we can solve both (12) and (13), and obtain
\[
\begin{align*}
\dot{J}_i &= \frac{1}{L_{ij} \sinh(u_{ij})} (e^{-u_{ij}} N_j T_j - e^{u_{ij}} N_i T_i) ; \\
\dot{S}_i &= \frac{1}{L_{ij} \sinh(u_{ij})} (e^{-u_{ij}} N_j T_j^2 - e^{u_{ij}} N_i T_i^2)
\end{align*}
\]
where \( L_{ij} \) is the distance between nodes \( i \) and \( j \), and \( u_{ij} = (\psi_j - \psi_i)/2 < T > \). \( T \) is normally a slowly-varying function of space, therefore the assumption of constant \( (1/T)(d\psi/dl) \) is justified. For instance, the approximation \( < T > = (T_i + T_j)/2 \) can be reasonable in practice. Moreover, the joule heating term in (2), \( F \cdot J \), can be included in the divergence operator by \( F \cdot J = -\nabla \cdot (\psi J) + \psi \nabla \cdot J \). If we define \( H = S + \psi J \) with the energy relaxation time approximation, (2) will become
\[
\nabla \cdot H = \nabla \cdot (S + \psi J) = \psi \cdot (G - R) - n \frac{< E > - E_0}{\tau_r}
\]
where \( E_0 = 3k_B T_0/2 \) and \( \tau_r \) is the energy relaxation time. The final normalized expression used in the fluxes through the sides of the finite boxes for the energy balance equation can be written as
\[
\begin{align*}
\dot{H}_i &= -C \dot{S}_i + \psi \dot{J}_i \\
&= \frac{1}{L_{ij} \sinh(u_{ij})} \left( e^{-u_{ij}} N_j T_j \left( \frac{\psi_j + \psi_i}{2} - C T_j \right) - e^{u_{ij}} N_i T_i \left( \frac{\psi_i + \psi_j}{2} - C T_i \right) \right).
\end{align*}
\]
4 Simulation Results

The new discretization method has been implemented in a 2-D device simulator based on the improved ET model using the full Newton method. Numerical tests have been carried out for a Si \( n^+ - n - n^+ \) structure with a 0.4 \( \mu \text{m} \) \( n \) region (see Fig. 1 and 2). Here the mobility model is chosen as \( \mu(T_m) = \mu_0 T_0 / T_m \), where \( \mu_0 \) is the low-field mobility. The energy relaxation time \( \tau_e \) is presently chosen as a constant. In both figures we vary \( p \) for illustration of the typical spurious velocity overshoot problem in the conventional HD models [11, 12]. In our formulation, the spurious peak is not only much reduced but also rather insensitive to the selection of \( p \) in contrary to the usual HD models. However, the accurate estimation of the velocity in the \( n \) region greatly depends on \( p \). This indicates that \( p \) should not be chosen randomly to eliminate the spurious peak as in many HD models. We can alternatively use \( p(T_m) \), extracted from the bulk MC results, in a more sophisticated model. The improved ET model appears very stable numerically. Quadratic convergence of the full Newton Scheme has been observed for every case with a good initial guess. We would like to point out again that non-parabolicity effects are already included in the formulation of the ET model. For GaAs device modeling, the field-induced anisotropy effect can also be included with little modification.

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References


Figure 1: Profiles of electron velocity in a Si $n^+ - n - n^+$ structure with a 0.4 $\mu m$ $n$ region and doping levels $n^+ = 5 \times 10^{17} cm^{-3}$, $n = 2 \times 10^{18} cm^{-3}$, with $p = 0.5, 1.0, 1.5$ and 2.0.

Figure 2: Distribution of the electron temperature for the structure in Fig. 1.